

FIG. 1

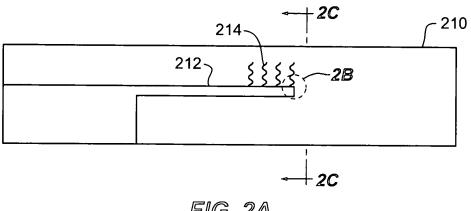
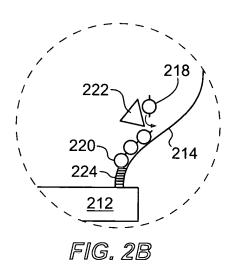


FIG. 2A



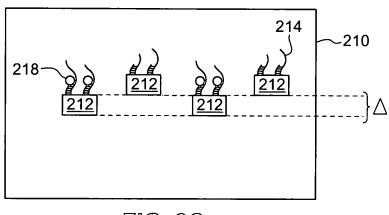


FIG. 2C

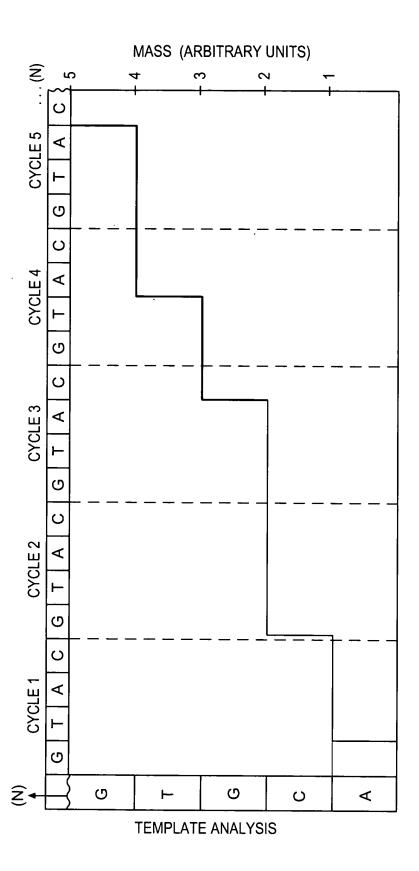


FIG. 3

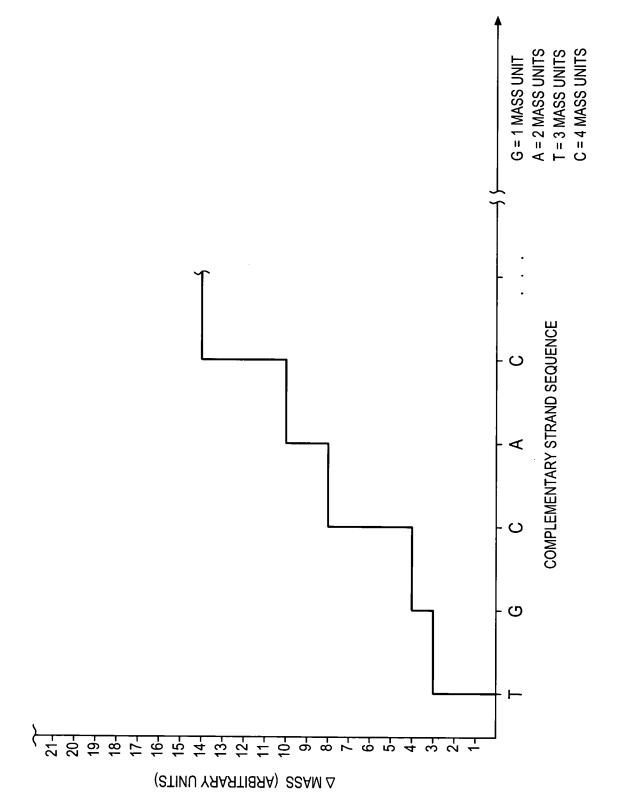
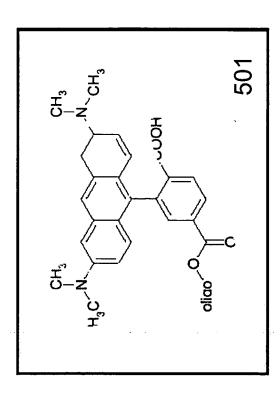


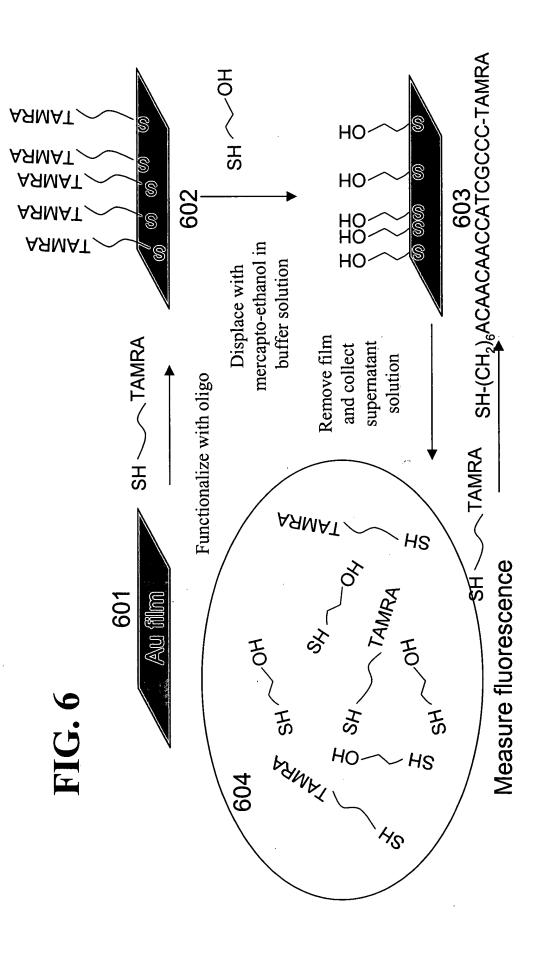
FIG. 4

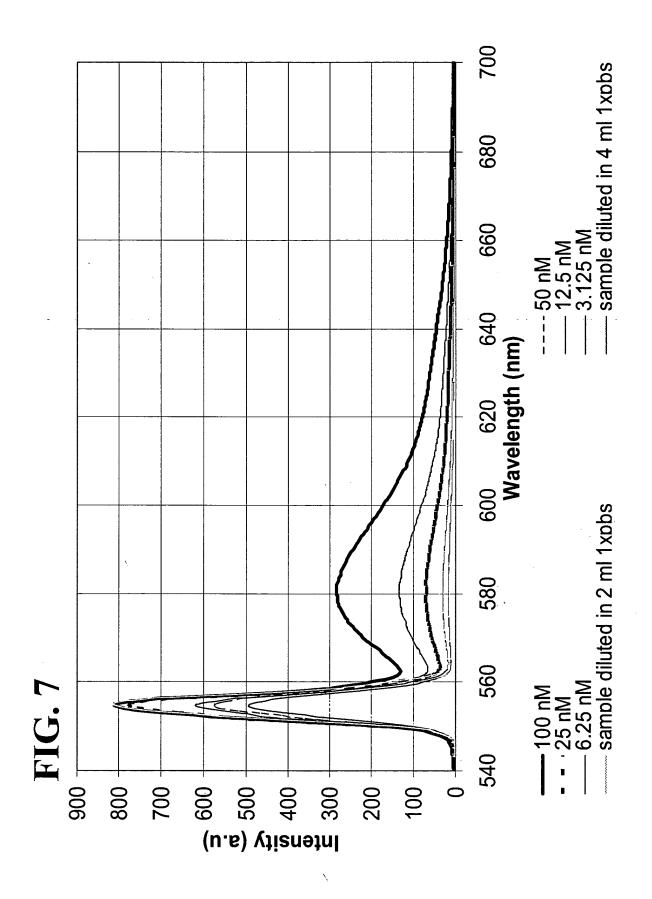
## FIG.5

- To confirm attachment of thiol-modified oligo (SH-1-f)
  [ThiSS]ACAACAACCATCGC CC-TAMRA) to a gold thin film and to determine the surface coverage
- Gold substrates prepared by sputtering using Metallica sputterer at SNF
- Ti 50 A, Au 1000 A on Silicon



IAMKA  $\lambda_{max,A}$ : 555 nm  $\lambda_{max,E}$ : 580 nm





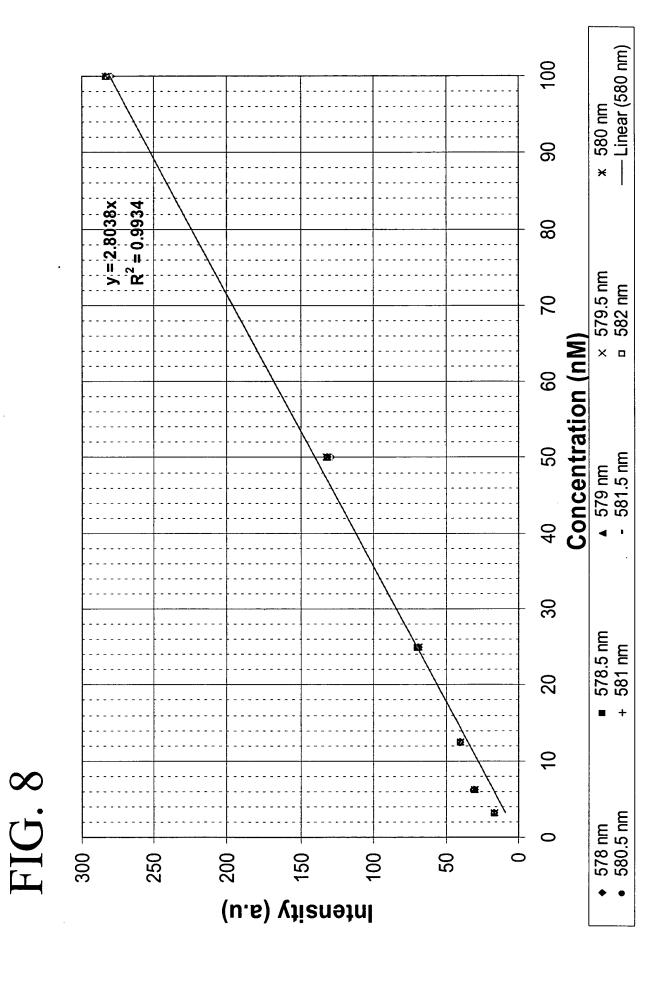


FIG. 9

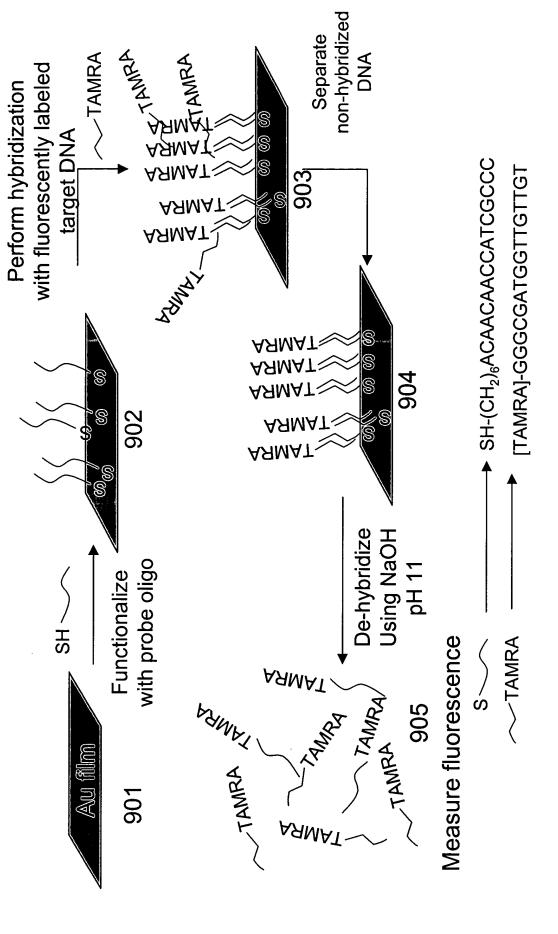


FIG.10

